ELSEVIER

Applied Surface Science 89 (1995) 422–424

applied surface science

Author index

Ahmed, M.F., see Ashour, A. 89 (1995) 159
Alnot, M., see Lobstein, N. 89 (1995) 307
Anandan, C., X-ray photoelectron spectroscopic study of room-temperature evolution of oxide-covered hydrogenated amorphous silicon/aluminium interface 89 (1995) 57
Arai, M., Y. Nishiyama, T. Masuda and K. Hashimoto, The distribution of activation energy for hydrogen desorption over silica-supported nickel catalysts determined from temperature-programmed desorption spectra 89 (1995) 11
Ashour, A., M.R. Ebeid, N. El-Kadry, M.F. Ahmed and A.A. Ramadan, Thermal effects on structural characterization of evaporated CdTe films during and after deposition 89 (1995) 159
Ayame, A., see Tomizuka, H. 89 (1995) 281

Bai, C., see Fang, Y. 89 (1995) 331
Bolt, P.H., S.F. Lobner, J.W. Geus and F.H.P.M. Habraken, Interfacial reaction of NiO with $Al_2O_3(11\bar{2}0)$ and polycrystalline α-Al_2O_3 89 (1995) 339
Bonnet, J., see Lévêque, G. 89 (1995) 211
Bram, Ch., see Starke, U. 89 (1995) 175
Butman, M.F., J. Nakamura, S. Kamidoi and H. Kawano, Influence of surface charge on thermal positive ion emission from potassium bromide 89 (1995) 323

Callegaro, L., see Vavassori, P. 89 (1995) 93
Cañón, M.G., see L'Argentière, P.C. 89 (1995) 63
Cerofolini, G.F. and L. Meda, Chemistry at silicon crystalline surfaces 89 (1995) 351
Cerofolini, G.F., G. La Bruna and L. Meda, Enhanced silicon oxidation in O_2 and O_2:F_2 89 (1995) 361
Chattopadhyay, P. and S. Sanyal, Capacitance–voltage characteristics of Schottky barrier diode in the presence of deep-level impurities and series resistance 89 (1995) 205
Chen, X. and Y. Wang, A study of the composition distribution at the Ti/Al_2O_3 interface using the MCs^+-SIMS technique 89 (1995) 169
Cheng, P., see Xue, G. 89 (1995) 77
Choi, J.-G., see Lee, H.J. 89 (1995) 121
Chopra, K.L., see Rao, M.V.H. 89 (1995) 417
Collaud-Coen, M., see Gröning, P. 89 (1995) 83
Colling, C.W., see Lee, H.J. 89 (1995) 121

Demanet, C.M., Atomic force microscopy determination of the topography of fly-ash particles 89 (1995) 97
Dietler, G., see Gröning, P. 89 (1995) 83
Ding, J., see Xue, G. 89 (1995) 77
Domínguez, P.S., see Tejedor, P. 89 (1995) 271
Donaton, R.A., K. Lokere, R. Verbeeck and K. Maex, Etching of $CoSi_2$ in HF-based solutions 89 (1995) 221

Ebeid, M.R., see Ashour, A. 89 (1995) 159
Ehrhardt, J.J., see Lobstein, N. 89 (1995) 307
El-Kadry, N., see Ashour, A. 89 (1995) 159

Fang, Y., C. Bai, T. Wang and Y.-Q. Tang, Characterization of triplex RNA poly [rU] · poly[rA] · poly[rU] adsorbed on silver colloids by Fourier transform surface enhanced Raman scattering and scanning tunneling microscopy 89 (1995) 331
Fígoli, N.S., see L'Argentière, P.C. 89 (1995) 63

Geus, J.W., see Bolt, P.H. 89 (1995) 339
Goldmann, A., see Kürpick, U. 89 (1995) 383
Gråsjö, L., G. Hultquist, K.L. Tan and M. Seo, Surface reactions on palladium hydride in vacuum, air and water studied in situ with mass spectrometry 89 (1995) 21
Gröning, P., O.M. Küttel, M. Collaud-Coen, G. Dietler and L. Schlapbach, Interaction of low-energy ions (< 10 eV) with polymethylmethacrylate during plasma treatment 89 (1995) 83
Gu, H.C., see Wang, X.K. 89 (1995) 297
Gunter, P.L.J. and J.W. Niemantsverdriet, Thickness determination of uniform overlayers on rough substrates by angle-dependent XPS 89 (1995) 69

Habraken, F.H.P.M., see Bolt, P.H. 89 (1995) 339
Hachimi, A., see Lobstein, N. 89 (1995) 307
Hadj Zoubir, N. and M. Vergnat, Thermal desorption spectroscopy study of chemically etched porous silicon 89 (1995) 35
Hammer, C.F., see Ye, X.R. 89 (1995) 151
Hammer, L., see Starke, U. 89 (1995) 175
Hanebuchi, M., T. Katoh and K. Morita, Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques 89 (1995) 113
Haneman, D., see Wu, S. 89 (1995) 289
Hartner, W., see Starke, U. 89 (1995) 175
Hashimoto, K., see Arai, M. 89 (1995) 11
Hautojärvi, P., see Vaara, T. 89 (1995) 103
Heinz, K., see Starke, U. 89 (1995) 175
Hong, J.K., I.-H. Oh, S.-A. Hong and W.Y. Lee, The effect of anodic polarization on a Ag electrode deposited on YSZ solid electrolyte 89 (1995) 229
Hong, S.-A., see Hong, J.K. 89 (1995) 229
Hou, H.W., see Ye, X.R. 89 (1995) 151
Hultquist, G., see Gråsjö, L. 89 (1995) 21

Ishida, H., see Yoshida, S. 89 (1995) 39
Ito, S., see Kameoka, S. 89 (1995) 411

Jo, B.H. and R.W. Vook, Dependence of electromigration rate on applied electric potential 89 (1995) 237

Kameoka, S., T. Kuriyama, M. Kuroda, S. Ito and K. Kunimori, The chemical interaction between plasma-excited nitrogen and the surface of titanium dioxide 89 (1995) 411
Kamidoi, S., see Butman, M.F. 89 (1995) 323
Katoh, T., see Hanebuchi, M. 89 (1995) 113
Kawano, H., see Butman, M.F. 89 (1995) 323
Kubo, M., R. Miura, R. Yamauchi, R. Vetrivel and A. Miyamoto, Mechanism of the formation of ultrafine gold particles on MgO(100) as investigated by molecular dynamics and computer graphics 89 (1995) 131
Kunimori, K., see Kameoka, S. 89 (1995) 411
Kuriyama, T., see Kameoka, S. 89 (1995) 411
Kuroda, M., see Kameoka, S. 89 (1995) 411
Kürpick, U., G. Meister and A. Goldmann, Diffusion of Ag on Cu(110) and Cu(111) studied by spatially resolved UV-photoemission 89 (1995) 383
Küttel, O.M., see Gröning, P. 89 (1995) 83

La Bruna, G., see Cerofolini, G.F. 89 (1995) 361
Lahtinen, J., see Vaara, T. 89 (1995) 103
L'Argentière, P.C., M.G. Cañón and N.S. Fígoli, XPS studies of the effect of Mn on Pd/Al_2O_3 89 (1995) 63
Lee, H.J., J.-G. Choi, C.W. Colling, M.S. Mudholkar and L.T. Thompson, Temperature-programmed desorption and decomposition of NH_3 over molybdenum nitride films 89 (1995) 121
Lee, W.Y., see Hong, J.K. 89 (1995) 229
Lévêque, G. and J. Bonnet, Quantitative correction of backscattering in Auger electron spectroscopy of thin films 89 (1995) 211
Li, Y.S., see Wong, P.C. 89 (1995) 255
Li, Y.S., P.C. Wong and K.A.R. Mitchell, XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma 89 (1995) 263
Linares-Solano, A., see Muñoz-Guillena, M.J. 89 (1995) 197
Lobner, S.F., see Bolt, P.H. 89 (1995) 339
Lobstein, N., E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt, Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate 89 (1995) 307
Lokere, K., see Donaton, R.A. 89 (1995) 221

Maex, K., see Donaton, R.A. 89 (1995) 221
Magni, E. and G.A. Somorjai, Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride 89 (1995) 187
Masuda, T., see Arai, M. 89 (1995) 11
Mathur, B.K., see Rao, M.V.H. 89 (1995) 417
Meda, L., see Cerofolini, G.F. 89 (1995) 351
Meda, L., see Cerofolini, G.F. 89 (1995) 361
Medvedev, A.S., see Shklyaev, A.A. 89 (1995) 49
Meister, G., see Kürpick, U. 89 (1995) 383
Millon, E., see Lobstein, N. 89 (1995) 307
Milun, M., see Valla, T. 89 (1995) 375
Mitchell, K.A.R., see Wong, P.C. 89 (1995) 255
Mitchell, K.A.R., see Li, Y.S. 89 (1995) 263
Miura, R., see Kubo, M. 89 (1995) 131
Miyamoto, A., see Kubo, M. 89 (1995) 131
Morita, K., see Hanebuchi, M. 89 (1995) 113
Mudholkar, M.S., see Lee, H.J. 89 (1995) 121
Muller, J.F., see Lobstein, N. 89 (1995) 307
Müller, K., see Starke, U. 89 (1995) 175
Muñoz-Guillena, M.J., A. Linares-Solano and C. Salinas-Martínez de Lecea, A new parameter to characterize limestones as SO_2 sorbents 89 (1995) 197

Nakamura, J., see Butman, M.F. 89 (1995) 323
Niemantsverdriet, J.W., see Gunter, P.L.J. 89 (1995) 69

Nishimura, Y., H. Ujita and M. Tsuji, Tantalum oxide film formation by excimer laser ablation 89 (1995) 393
Nishiyama, Y., see Arai, M. 89 (1995) 11

Oh, I.-H., see Hong, J.K. 89 (1995) 229

Pervan, P., see Valla, T. 89 (1995) 375
Porto, A., see Scandurra, A. 89 (1995) 1
Powell, C.J., Elemental binding energies for X-ray photoelectron spectroscopy 89 (1995) 141
Puglisi, O., see Scandurra, A. 89 (1995) 1
Puppin, E., see Vavassori, P. 89 (1995) 93

Qiu, S.-L., see Ruckman, M.W. 89 (1995) 401

Ramadan, A.A., see Ashour, A. 89 (1995) 159
Rao, M.V.H., V. Srinivas, V.V. Rao, B.K. Mathur and K.L. Chopra, Observation of field-induced fragmentation of nickel clusters using Scanning Tunneling Microscopy 89 (1995) 417
Rao, V.V., see Rao, M.V.H. 89 (1995) 417
Ruckman, M.W., S.-L. Qiu and M. Strongin, A photoelectron study of the oxidation of Ta(110) and thin aluminum layers on Ta(110) 89 (1995) 401

Salinas-Martínez de Lecea, C., see Muñoz-Guillena, M.J. 89 (1995) 197
Sanyal, S., see Chattopadhyay, P. 89 (1995) 205
Scandurra, A., A. Porto and O. Puglisi, SIMS microprofiles of Pb-5%Sn solder joints in electronic devices after accelerated life tests 89 (1995) 1
Schlapbach, L., see Gröning, P. 89 (1995) 83
Seo, M., see Gråsjö, L. 89 (1995) 21
Shen, N.F., see Wang, X.K. 89 (1995) 297
Shklyaev, A.A. and A.S. Medvedev, Plasma-enhanced reactively evaporated deposition of SiO_2 films 89 (1995) 49
Somorjai, G.A., see Magni, E. 89 (1995) 187
Srinivas, V., see Rao, M.V.H. 89 (1995) 417
Starke, U., Ch. Bram, P.-R. Steiner, W. Hartner, L. Hammer, K. Heinz and K. Müller, The (0001)-surface of 6H-SiC: morphology, composition and structure 89 (1995) 175
Steiner, P.-R., see Starke, U. 89 (1995) 175
Strongin, M., see Ruckman, M.W. 89 (1995) 401

Tan, K.L., see Gråsjö, L. 89 (1995) 21
Tang, Y.-Q., see Fang, Y. 89 (1995) 331
Tejedor, P. and P.S. Domínguez, Surface kinetics and morphology of ArF laser-assisted etching of (113)A GaAs in a Cl_2 environment 89 (1995) 271
Thompson, L.T., see Lee, H.J. 89 (1995) 121
Tomizuka, H. and A. Ayame, A graphical analysis of transient response curves at an early stage in SIMS depth profiling using a $^{133}Cs^+$ beam 89 (1995) 281
Tsuji, M., see Nishimura, Y. 89 (1995) 393

Ujita, H., see Nishimura, Y. 89 (1995) 393

Vaara, T., J. Lahtinen and P. Hautojärvi, Reactions of CO and NO on Mg promoted cobalt 89 (1995) 103
Valla, T., P. Pervan and M. Milun, Interaction of oxygen and silver on the V(100) surface 89 (1995) 375
Vavassori, P., L. Callegaro and E. Puppin, Ultraviolet inverse photoemission study of the oxidation of YFe_2 89 (1995) 93
Verbeeck, R., see Donaton, R.A. 89 (1995) 221
Vergnat, M., see Hadj Zoubir, N. 89 (1995) 35
Vetrivel, R., see Kubo, M. 89 (1995) 131
Vook, R.W., see Jo, B.H. 89 (1995) 237

Wang, T., see Fang, Y. 89 (1995) 331
Wang, X.K., N.F. Shen, Z.S. Yang and H.C. Gu, Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2Al_{0.2}$ catalysts 89 (1995) 297
Wang, Y., see Chen, X. 89 (1995) 169
Wong, P.C., Y.S. Li, M.Y. Zhou and K.A.R. Mitchell, XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film 89 (1995) 255
Wong, P.C., see Li, Y.S. 89 (1995) 263
Wu, S. and D. Haneman, Cadmium selenide–amorphous hydrogenated silicon heterostructures 89 (1995) 289

Xin, X.Q., see Ye, X.R. 89 (1995) 151
Xue, G., J. Ding and P. Cheng, Growth of a surface film on copper from benzotriazole solutions 89 (1995) 77

Yamauchi, R., see Kubo, M. 89 (1995) 131
Yanagisawa, Y., Oxygen exchange between adsorbed NO and MgO surfaces 89 (1995) 251
Yang, Z.S., see Wang, X.K. 89 (1995) 297
Ye, X.R., H.W. Hou, X.Q. Xin and C.F. Hammer, M–S (M = Mo, W) cluster compound films on copper surfaces 89 (1995) 151
Yoshida, S. and H. Ishida, An investigation of the thermal stability of undecylimidazole on copper by FT-IR reflection–absorption spectroscopy 89 (1995) 39

Zhou, M.Y., see Wong, P.C. 89 (1995) 255

ELSEVIER

Applied Surface Science 89 (1995) 425–434

applied surface science

Subject index

Ablation

Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307

Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393

Alkali metals

A graphical analysis of transient response curves at an early stage in SIMS depth profiling using a $^{133}Cs^{+}$ beam, H. Tomizuka and A. Ayame 89 (1995) 281

Influence of surface charge on thermal positive ion emission from potassium bromide, M.F. Butman, J. Nakamura, S. Kamidoi and H. Kawano 89 (1995) 323

Alloys

SIMS microprofiles of Pb-5%Sn solder joints in electronic devices after accelerated life tests, A. Scandurra, A. Porto and O. Puglisi 89 (1995) 1

Ultraviolet inverse photoemission study of the oxidation of YFe_2, P. Vavassori, L. Callegaro and E. Puppin 89 (1995) 93

Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

Aluminium

X-ray photoelectron spectroscopic study of room-temperature evolution of oxide-covered hydrogenated amorphous silicon/aluminium interface, C. Anandan 89 (1995) 57

Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

A photoelectron study of the oxidation of Ta(110) and thin aluminum layers on Ta(110), M.W. Ruckman, S.-L. Qiu and M. Strongin 89 (1995) 401

Aluminium oxide

XPS studies of the effect of Mn on Pd/Al_2O_3, P.C. L'Argentière, M.G. Cañón and N.S. Fígoli 89 (1995) 63

A study of the composition distribution at the Ti/Al_2O_3 interface using the MCs^{+}-SIMS technique, X. Chen and Y. Wang 89 (1995) 169

Interfacial reaction of NiO with Al_2O_3 $(11\bar{2}0)$ and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Ammonia

Temperature-programmed desorption and decomposition of NH_3 over molybdenum nitride films, H.J. Lee, J.-G. Choi, C.W. Colling, M.S. Mudholkar and L.T. Thompson 89 (1995) 121

Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

Atomic force microscopy

Thickness determination of uniform overlayers on rough substrates by angle-dependent XPS, P.L.J. Gunter and J.W. Niemantsverdriet 89 (1995) 69

Atomic force microscopy determination of the topography of fly-ash particles, C.M. Demanet 89 (1995) 97

Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307

Auger electron spectroscopy

Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113
M–S (M = Mo, W) cluster compound films on copper surfaces, X.R. Ye, H.W. Hou, X.Q. Xin and C.F. Hammer 89 (1995) 151
Quantitative correction of backscattering in Auger electron spectroscopy of thin films, G. Lévêque and J. Bonnet 89 (1995) 211
Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297
Interaction of oxygen and silver on the V(100) surface, T. Valla, P. Pervan and M. Milun 89 (1995) 375

Cadmium selenide

Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289

Cadmium telluride

Thermal effects on structural characterization of evaporated CdTe films during and after deposition, A. Ashour, M.R. Ebeid, N. El-Kadry, M.F. Ahmed and A.A. Ramadan 89 (1995) 159

Calcium

A new parameter to characterize limestones as SO_2 sorbents, M.J. Muñoz-Guillena, A. Linares-Solano and C. Salinas-Martínez de Lecea 89 (1995) 197

Carbon monoxide

Reactions of CO and NO on Mg promoted cobalt, T. Vaara, J. Lahtinen and P. Hautojärvi 89 (1995) 103

Catalysis

The distribution of activation energy for hydrogen desorption over silica-supported nickel catalysts determined from temperature-programmed desorption spectra, M. Arai, Y. Nishiyama, T. Masuda and K. Hashimoto 89 (1995) 11
Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride, E. Magni and G.A. Somorjai 89 (1995) 187
Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

Cobalt

Reactions of CO and NO on Mg promoted cobalt, T. Vaara, J. Lahtinen and P. Hautojärvi 89 (1995) 103
Etching of $CoSi_2$ in HF-based solutions, R.A. Donaton, K. Lokere, R. Verbeeck and K. Maex 89 (1995) 221
Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

Computer simulations

Mechanism of the formation of ultrafine gold particles on MgO(100) as investigated by molecular dynamics and computer graphics, M. Kubo, R. Miura, R. Yamauchi, R. Vetrivel and A. Miyamoto 89 (1995) 131

Copper

An investigation of the thermal stability of undecylimidazole on copper by FT-IR reflection–absorption spectroscopy, S. Yoshida and H. Ishida 89 (1995) 39
Growth of a surface film on copper from benzotriazole solutions, G. Xue, J. Ding and P. Cheng 89 (1995) 77
M–S (M = Mo, W) cluster compound films on copper surfaces, X.R. Ye, H.W. Hou, X.Q. Xin and C.F. Hammer 89 (1995) 151
Dependence of electromigration rate on applied electric potential, B.H. Jo and R.W. Vook 89 (1995) 237
Diffusion of Ag on Cu(110) and Cu(111) studied by spatially resolved UV-photo-

emission, U. Kürpick, G. Meister and A. Goldmann 89 (1995) 383

Electrical properties

Capacitance–voltage characteristics of Schottky barrier diode in the presence of deep-level impurities and series resistance, P. Chattopadhyay and S. Sanyal 89 (1995) 205
Dependence of electromigration rate on applied electric potential, B.H. Jo and R.W. Vook 89 (1995) 237
Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289
Influence of surface charge on thermal positive ion emission from potassium bromide, M.F. Butman, J. Nakamura, S. Kamidoi and H. Kawano 89 (1995) 323

Electromigration

Dependence of electromigration rate on applied electric potential, B.H. Jo and R.W. Vook 89 (1995) 237

Electron diffraction

Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113

Electron energy loss spectroscopy

The (0001)-surface of 6H-SiC: morphology, composition and structure, U. Starke, Ch. Bram, P.-R. Steiner, W. Hartner, L. Hammer, K. Heinz and K. Müller 89 (1995) 175

Electron microscopy

Etching of $CoSi_2$ in HF-based solutions, R.A. Donaton, K. Lokere, R. Verbeeck and K. Maex 89 (1995) 221
The effect of anodic polarization on a Ag electrode deposited on YSZ solid electrolyte, J.K. Hong, I.-H. Oh, S.-A. Hong and W.Y. Lee 89 (1995) 229
Dependence of electromigration rate on applied electric potential, B.H. Jo and R.W. Vook 89 (1995) 237
Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2$ $Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297
Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307
Interfacial reaction of NiO with Al_2O_3 $(11\bar{2}0)$ and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Ellipsometry

Plasma-enhanced reactively evaporated deposition of SiO_2 films, A.A. Shklyaev and A.S. Medvedev 89 (1995) 49
Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307
Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393

Epitaxy

Diffusion of Ag on Cu(110) and Cu(111) studied by spatially resolved UV-photoemission, U. Kürpick, G. Meister and A. Goldmann 89 (1995) 383

Etching

Etching of $CoSi_2$ in HF-based solutions, R.A. Donaton, K. Lokere, R. Verbeeck and K. Maex 89 (1995) 221
Surface kinetics and morphology of ArF laser-assisted etching of (113)A GaAs in a Cl_2 environment, P. Tejedor and P.S. Domínguez 89 (1995) 271

Evaporation

Thermal effects on structural characterization of evaporated CdTe films during and after deposition, A. Ashour, M.R. Ebeid, N. El-Kadry, M.F. Ahmed and A.A. Ramadan 89 (1995) 159
Dependence of electromigration rate on applied electric potential, B.H. Jo and R.W. Vook 89 (1995) 237

Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289
Interfacial reaction of NiO with Al_2O_3 ($11\bar{2}0$) and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Gallium arsenide

Surface kinetics and morphology of ArF laser-assisted etching of (113)A GaAs in a Cl_2 environment, P. Tejedor and P.S. Domínguez 89 (1995) 271

Gold

Mechanism of the formation of ultrafine gold particles on MgO(100) as investigated by molecular dynamics and computer graphics, M. Kubo, R. Miura, R. Yamauchi, R. Vetrivel and A. Miyamoto 89 (1995) 131
Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride, E. Magni and G.A. Somorjai 89 (1995) 187

Halogenides

Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride, E. Magni and G.A. Somorjai 89 (1995) 187
Influence of surface charge on thermal positive ion emission from potassium bromide, M.F. Butman, J. Nakamura, S. Kamidoi and H. Kawano 89 (1995) 323

Hydrides

Surface reactions on palladium hydride in vacuum, air and water studied in situ with mass spectrometry, L. Gråsjö, G. Hultquist, K.L. Tan and M. Seo 89 (1995) 21

Hydrocarbons

An investigation of the thermal stability of undecylimidazole on copper by FT-IR reflection–absorption spectroscopy, S. Yoshida and H. Ishida 89 (1995) 39
Growth of a surface film on copper from benzotriazole solutions, G. Xue, J. Ding and P. Cheng 89 (1995) 77

Hydrogen

The distribution of activation energy for hydrogen desorption over silica-supported nickel catalysts determined from temperature-programmed desorption spectra, M. Arai, Y. Nishiyama, T. Masuda and K. Hashimoto 89 (1995) 11
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film, P.C. Wong, Y.S. Li, M.Y. Zhou and K.A.R. Mitchell 89 (1995) 255
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma, Y.S. Li, P.C. Wong and K.A.R. Mitchell 89 (1995) 263
Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289

Indium phosphide

Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113

Infrared spectroscopy

An investigation of the thermal stability of undecylimidazole on copper by FT-IR reflection–absorption spectroscopy, S. Yoshida and H. Ishida 89 (1995) 39
Plasma-enhanced reactively evaporated deposition of SiO_2 films, A.A. Shklyaev and A.S. Medvedev 89 (1995) 49
Growth of a surface film on copper from benzotriazole solutions, G. Xue, J. Ding and P. Cheng 89 (1995) 77
M–S (M = Mo, W) cluster compound films on copper surfaces, X.R. Ye, H.W. Hou, X.Q. Xin and C.F. Hammer 89 (1995) 151
The chemical interaction between plasma-excited nitrogen and the surface of titanium dioxide, S. Kameoka, T. Kuriyama, M. Kuroda, S. Ito and K. Kunimori 89 (1995) 411

Interfaces

X-ray photoelectron spectroscopic study of room-temperature evolution of oxide-

covered hydrogenated amorphous silicon/aluminium interface, C. Anandan 89 (1995) 57
A study of the composition distribution at the Ti/Al_2O_3 interface using the MCs^+-SIMS technique, X. Chen and Y. Wang 89 (1995) 169

Ion scattering

Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113
Etching of $CoSi_2$ in HF-based solutions, R.A. Donaton, K. Lokere, R. Verbeeck and K. Maex 89 (1995) 221
Interfacial reaction of NiO with Al_2O_3 ($11\bar{2}0$) and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Iron

Ultraviolet inverse photoemission study of the oxidation of YFe_2, P. Vavassori, L. Callegaro and E. Puppin 89 (1995) 93
Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

Laser processing

Surface kinetics and morphology of ArF laser-assisted etching of (113)A GaAs in a Cl_2 environment, P. Tejedor and P.S. Domínguez 89 (1995) 271
Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393

Lead

SIMS microprofiles of Pb-5%Sn solder joints in electronic devices after accelerated life tests, A. Scandurra, A. Porto and O. Puglisi 89 (1995) 1

Low energy electron diffraction

Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113
The (0001)-surface of 6H-SiC: morphology, composition and structure, U. Starke, Ch. Bram, P.-R. Steiner, W. Hartner, L. Hammer, K. Heinz and K. Müller 89 (1995) 175

Magnesium

Reactions of CO and NO on Mg promoted cobalt, T. Vaara, J. Lahtinen and P. Hautojärvi 89 (1995) 103
Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride, E. Magni and G.A. Somorjai 89 (1995) 187

Magnesium oxide

Mechanism of the formation of ultrafine gold particles on MgO(100) as investigated by molecular dynamics and computer graphics, M. Kubo, R. Miura, R. Yamauchi, R. Vetrivel and A. Miyamoto 89 (1995) 131
Oxygen exchange between adsorbed NO and MgO surfaces, Y. Yanagisawa 89 (1995) 251

Manganese

XPS studies of the effect of Mn on Pd/Al_2O_3, P.C. L'Argentière, M.G. Cañón and N.S. Fígoli 89 (1995) 63

Mass spectroscopy

Surface reactions on palladium hydride in vacuum, air and water studied in situ with mass spectrometry, L. Gråsjö, G. Hultquist, K.L. Tan and M. Seo 89 (1995) 21

Molybdenum

Temperature-programmed desorption and decomposition of NH_3 over molybdenum nitride films, H.J. Lee, J.-G. Choi, C.W. Colling, M.S. Mudholkar and L.T. Thompson 89 (1995) 121
M–S (M = Mo, W) cluster compound films on copper surfaces, X.R. Ye, H.W. Hou, X.Q. Xin and C.F. Hammer 89 (1995) 151

Nickel

Interfacial reaction of NiO with Al_2O_3 ($11\bar{2}0$) and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Observation of field-induced fragmentation of nickel clusters using Scanning Tunneling Microscopy, M.V.H. Rao, V. Srinivas, V.V. Rao, B.K. Mathur and K.L. Chopra 89 (1995) 417

Nitric oxide

Reactions of CO and NO on Mg promoted cobalt, T. Vaara, J. Lahtinen and P. Hautojärvi 89 (1995) 103

Oxygen exchange between adsorbed NO and MgO surfaces, Y. Yanagisawa 89 (1995) 251

Nitrides

Temperature-programmed desorption and decomposition of NH_3 over molybdenum nitride films, H.J. Lee, J.-G. Choi, C.W. Colling, M.S. Mudholkar and L.T. Thompson 89 (1995) 121

Nitrogen

The chemical interaction between plasma-excited nitrogen and the surface of titanium dioxide, S. Kameoka, T. Kuriyama, M. Kuroda, S. Ito and K. Kunimori 89 (1995) 411

Oxidation

Ultraviolet inverse photoemission study of the oxidation of YFe_2, P. Vavassori, L. Callegaro and E. Puppin 89 (1995) 93

Enhanced silicon oxidation in O_2 and O_2:F_2, G.F. Cerofolini, G. La Bruna and L. Meda 89 (1995) 361

A photoelectron study of the oxidation of Ta(110) and thin aluminum layers on Ta(110), M.W. Ruckman, S.-L. Qiu and M. Strongin 89 (1995) 401

Oxides

A new parameter to characterize limestones as SO_2 sorbents, M.J. Muñoz-Guillena, A. Linares-Solano and C. Salinas-Martínez de Lecea 89 (1995) 197

XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film, P.C. Wong, Y.S. Li, M.Y. Zhou and K.A.R. Mitchell 89 (1995) 255

XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma, Y.S. Li, P.C. Wong and K.A.R. Mitchell 89 (1995) 263

Interfacial reaction of NiO with Al_2O_3 ($11\bar{2}0$) and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393

Oxygen

Interaction of oxygen and silver on the V(100) surface, T. Valla, P. Pervan and M. Milun 89 (1995) 375

Palladium

Surface reactions on palladium hydride in vacuum, air and water studied in situ with mass spectrometry, L. Gråsjö, G. Hultquist, K.L. Tan and M. Seo 89 (1995) 21

XPS studies of the effect of Mn on Pd/Al_2O_3, P.C. L'Argentière, M.G. Cañón and N.S. Fígoli 89 (1995) 63

Photoelectron spectroscopy

Plasma-enhanced reactively evaporated deposition of SiO_2 films, A.A. Shklyaev and A.S. Medvedev 89 (1995) 49

X-ray photoelectron spectroscopic study of room-temperature evolution of oxide-covered hydrogenated amorphous silicon/aluminium interface, C. Anandan 89 (1995) 57

XPS studies of the effect of Mn on Pd/Al_2O_3, P.C. L'Argentière, M.G. Cañón and N.S. Fígoli 89 (1995) 63

Thickness determination of uniform overlayers on rough substrates by angle-dependent XPS, P.L.J. Gunter and J.W. Niemantsverdriet 89 (1995) 69

Interaction of low-energy ions (< 10 eV) with polymethylmethacrylate during plasma treatment, P. Gröning, O.M. Küttel, M. Collaud-Coen, G. Dietler and L. Schlapbach 89 (1995) 83

Reactions of CO and NO on Mg promoted cobalt, T. Vaara, J. Lahtinen and P. Hautojärvi 89 (1995) 103
Elemental binding energies for X-ray photoelectron spectroscopy, C.J. Powell 89 (1995) 141
M–S (M = Mo, W) cluster compound films on copper surfaces, X.R. Ye, H.W. Hou, X.Q. Xin and C.F. Hammer 89 (1995) 151
The effect of anodic polarization on a Ag electrode deposited on YSZ solid electrolyte, J.K. Hong, I.-H. Oh, S.-A. Hong and W.Y. Lee 89 (1995) 229
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film, P.C. Wong, Y.S. Li, M.Y. Zhou and K.A.R. Mitchell 89 (1995) 255
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma, Y.S. Li, P.C. Wong and K.A.R. Mitchell 89 (1995) 263
A graphical analysis of transient response curves at an early stage in SIMS depth profiling using a $^{133}Cs^+$ beam, H. Tomizuka and A. Ayame 89 (1995) 281
Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297
Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307
Interaction of oxygen and silver on the V(100) surface, T. Valla, P. Pervan and M. Milun 89 (1995) 375
Diffusion of Ag on Cu(110) and Cu(111) studied by spatially resolved UV-photoemission, U. Kürpick, G. Meister and A. Goldmann 89 (1995) 383
Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393
A photoelectron study of the oxidation of Ta(110) and thin aluminum layers on Ta(110), M.W. Ruckman, S.-L. Qiu and M. Strongin 89 (1995) 401

Photoemission

Ultraviolet inverse photoemission study of the oxidation of YFe_2, P. Vavassori, L. Callegaro and E. Puppin 89 (1995) 93

Plasma processing

Plasma-enhanced reactively evaporated deposition of SiO_2 films, A.A. Shklyaev and A.S. Medvedev 89 (1995) 49
Interaction of low-energy ions (< 10 eV) with polymethylmethacrylate during plasma treatment, P. Gröning, O.M. Küttel, M. Collaud-Coen, G. Dietler and L. Schlapbach 89 (1995) 83
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film, P.C. Wong, Y.S. Li, M.Y. Zhou and K.A.R. Mitchell 89 (1995) 255
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma, Y.S. Li, P.C. Wong and K.A.R. Mitchell 89 (1995) 263
Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289
The chemical interaction between plasma-excited nitrogen and the surface of titanium dioxide, S. Kameoka, T. Kuriyama, M. Kuroda, S. Ito and K. Kunimori 89 (1995) 411

Polymers

An investigation of the thermal stability of undecylimidazole on copper by FT-IR reflection–absorption spectroscopy, S. Yoshida and H. Ishida 89 (1995) 39
Growth of a surface film on copper from benzotriazole solutions, G. Xue, J. Ding and P. Cheng 89 (1995) 77
Interaction of low-energy ions (< 10 eV) with polymethylmethacrylate during plasma treatment, P. Gröning, O.M. Küttel, M. Collaud-Coen, G. Dietler and L. Schlapbach 89 (1995) 83
Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307
Characterization of triplex RNA poly[rU] · poly[rA] · poly[rU] adsorbed on silver colloids by Fourier transform surface enhanced Raman scattering and scanning tunneling microscopy, Y. Fang, C. Bai, T. Wang and Y.-Q. Tang 89 (1995) 331

Raman scattering

Growth of a surface film on copper from benzotriazole solutions, G. Xue, J. Ding and P. Cheng 89 (1995) 77

Characterization of triplex RNA poly[rU] · poly[rA] · poly[rU] adsorbed on silver colloids by Fourier transform surface enhanced Raman scattering and scanning tunneling microscopy, Y. Fang, C. Bai, T. Wang and Y.-Q. Tang 89 (1995) 331

Scanning tunneling microscopy

The (0001)-surface of 6H-SiC: morphology, composition and structure, U. Starke, Ch. Bram, P.-R. Steiner, W. Hartner, L. Hammer, K. Heinz and K. Müller 89 (1995) 175

Characterization of triplex RNA poly[rU] · poly[rA] · poly[rU] adsorbed on silver colloids by Fourier transform surface enhanced Raman scattering and scanning tunneling microscopy, Y. Fang, C. Bai, T. Wang and Y.-Q. Tang 89 (1995) 331

Observation of field-induced fragmentation of nickel clusters using Scanning Tunneling Microscopy, M.V.H. Rao, V. Srinivas, V.V. Rao, B.K. Mathur and K.L. Chopra 89 (1995) 417

Schottky barrier

Capacitance–voltage characteristics of Schottky barrier diode in the presence of deep-level impurities and series resistance, P. Chattopadhyay and S. Sanyal 89 (1995) 205

Secondary ion mass spectrometry

SIMS microprofiles of Pb-5%Sn solder joints in electronic devices after accelerated life tests, A. Scandurra, A. Porto and O. Puglisi 89 (1995) 1

A study of the composition distribution at the Ti/Al_2O_3 interface using the MCs^+-SIMS technique, X. Chen and Y. Wang 89 (1995) 169

A graphical analysis of transient response curves at an early stage in SIMS depth profiling using a $^{133}Cs^+$ beam, H. Tomizuka and A. Ayame 89 (1995) 281

Silicides

Etching of $CoSi_2$ in HF-based solutions, R.A. Donaton, K. Lokere, R. Verbeeck and K. Maex 89 (1995) 221

Silicon

Thermal desorption spectroscopy study of chemically etched porous silicon, N. Hadj Zoubir and M. Vergnat 89 (1995) 35

X-ray photoelectron spectroscopic study of room-temperature evolution of oxide-covered hydrogenated amorphous silicon/aluminium interface, C. Anandan 89 (1995) 57

A graphical analysis of transient response curves at an early stage in SIMS depth profiling using a $^{133}Cs^+$ beam, H. Tomizuka and A. Ayame 89 (1995) 281

Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289

Chemistry at silicon crystalline surfaces, G.F. Cerofolini and L. Meda 89 (1995) 351

Enhanced silicon oxidation in O_2 and O_2:F_2, G.F. Cerofolini, G. La Bruna and L. Meda 89 (1995) 361

Silicon carbide

The (0001)-surface of 6H-SiC: morphology, composition and structure, U. Starke, Ch. Bram, P.-R. Steiner, W. Hartner, L. Hammer, K. Heinz and K. Müller 89 (1995) 175

Silicon oxide

Plasma-enhanced reactively evaporated deposition of SiO_2 films, A.A. Shklyaev and A.S. Medvedev 89 (1995) 49

A graphical analysis of transient response curves at an early stage in SIMS depth profiling using a $^{133}Cs^+$ beam, H. Tomizuka and A. Ayame 89 (1995) 281

Silver

Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113

The effect of anodic polarization on a Ag electrode deposited on YSZ solid electrolyte, J.K. Hong, I.-H. Oh, S.-A. Hong and W.Y. Lee 89 (1995) 229

Interaction of oxygen and silver on the V(100) surface, T. Valla, P. Pervan and M. Milun 89 (1995) 375

Diffusion of Ag on Cu(110) and Cu(111) studied by spatially resolved UV-photo-

emission, U. Kürpick, G. Meister and A. Goldmann 89 (1995) 383

Sulphur dioxide

A new parameter to characterize limestones as SO_2 sorbents, M.J. Muñoz-Guillena, A. Linares-Solano and C. Salinas-Martínez de Lecea 89 (1995) 197

Tantalum

Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393
A photoelectron study of the oxidation of Ta(110) and thin aluminum layers on Ta(110), M.W. Ruckman, S.-L. Qiu and M. Strongin 89 (1995) 401

Thermal desorption

The distribution of activation energy for hydrogen desorption over silica-supported nickel catalysts determined from temperature-programmed desorption spectra, M. Arai, Y. Nishiyama, T. Masuda and K. Hashimoto 89 (1995) 11
Thermal desorption spectroscopy study of chemically etched porous silicon, N. Hadj Zoubir and M. Vergnat 89 (1995) 35
Reactions of CO and NO on Mg promoted cobalt, T. Vaara, J. Lahtinen and P. Hautojärvi 89 (1995) 103
Temperature-programmed desorption and decomposition of NH_3 over molybdenum nitride films, H.J. Lee, J.-G. Choi, C.W. Colling, M.S. Mudholkar and L.T. Thompson 89 (1995) 121
Oxygen exchange between adsorbed NO and MgO surfaces, Y. Yanagisawa 89 (1995) 251

Thin films

Plasma-enhanced reactively evaporated deposition of SiO_2 films, A.A. Shklyaev and A.S. Medvedev 89 (1995) 49
Characterization of thin Ag films deposited onto InP(001)-p(2×4) surface at room temperature by means of LEED, RHEED, AES and RBS-channeling techniques, M. Hanebuchi, T. Katoh and K. Morita 89 (1995) 113
Temperature-programmed desorption and decomposition of NH_3 over molybdenum nitride films, H.J. Lee, J.-G. Choi, C.W. Colling, M.S. Mudholkar and L.T. Thompson 89 (1995) 121
Thermal effects on structural characterization of evaporated CdTe films during and after deposition, A. Ashour, M.R. Ebeid, N. El-Kadry, M.F. Ahmed and A.A. Ramadan 89 (1995) 159
Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride, E. Magni and G.A. Somorjai 89 (1995) 187
Quantitative correction of backscattering in Auger electron spectroscopy of thin films, G. Lévêque and J. Bonnet 89 (1995) 211
Dependence of electromigration rate on applied electric potential, B.H. Jo and R.W. Vook 89 (1995) 237
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film, P.C. Wong, Y.S. Li, M.Y. Zhou and K.A.R. Mitchell 89 (1995) 255
XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma, Y.S. Li, P.C. Wong and K.A.R. Mitchell 89 (1995) 263
Cadmium selenide–amorphous hydrogenated silicon heterostructures, S. Wu and D. Haneman 89 (1995) 289
Interfacial reaction of NiO with Al_2O_3 ($11\bar{2}0$) and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339
Interaction of oxygen and silver on the V(100) surface, T. Valla, P. Pervan and M. Milun 89 (1995) 375
Tantalum oxide film formation by excimer laser ablation, Y. Nishimura, H. Ujita and M. Tsuji 89 (1995) 393

Tin

SIMS microprofiles of Pb-5%Sn solder joints in electronic devices after accelerated life tests, A. Scandurra, A. Porto and O. Puglisi 89 (1995) 1

Titanium

A study of the composition distribution at the Ti/Al_2O_3 interface using the MCs^+-SIMS technique, X. Chen and Y. Wang 89 (1995) 169

Preparation of a model Ziegler–Natta catalyst. Surface science studies of magnesium chloride thin film deposited on gold and its interaction with titanium chloride, E. Magni and G.A. Somorjai 89 (1995) 187

Titanium oxide

Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307

The chemical interaction between plasma-excited nitrogen and the surface of titanium dioxide, S. Kameoka, T. Kuriyama, M. Kuroda, S. Ito and K. Kunimori 89 (1995) 411

Tungsten

M–S (M = Mo, W) cluster compound films on copper surfaces, X.R. Ye, H.W. Hou, X.Q. Xin and C.F. Hammer 89 (1995) 151

Vanadium

Interaction of oxygen and silver on the V(100) surface, T. Valla, P. Pervan and M. Milun 89 (1995) 375

Water

Surface reactions on palladium hydride in vacuum, air and water studied in situ with mass spectrometry, L. Gråsjö, G. Hultquist, K.L. Tan and M. Seo 89 (1995) 21

X-ray diffraction

Thermal effects on structural characterization of evaporated CdTe films during and after deposition, A. Ashour, M.R. Ebeid, N. El-Kadry, M.F. Ahmed and A.A. Ramadan 89 (1995) 159

Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297

Deposition by laser ablation and characterization of titanium dioxide films on polyethylene-terephthalate, N. Lobstein, E. Millon, A. Hachimi, J.F. Muller, M. Alnot and J.J. Ehrhardt 89 (1995) 307

Interfacial reaction of NiO with Al_2O_3 $(11\bar{2}0)$ and polycrystalline α-Al_2O_3, P.H. Bolt, S.F. Lobner, J.W. Geus and F.H.P.M. Habraken 89 (1995) 339

Yttrium

Ultraviolet inverse photoemission study of the oxidation of YFe_2, P. Vavassori, L. Callegaro and E. Puppin 89 (1995) 93

The effect of anodic polarization on a Ag electrode deposited on YSZ solid electrolyte, J.K. Hong, I.-H. Oh, S.-A. Hong and W.Y. Lee 89 (1995) 229

Zirconium

The effect of anodic polarization on a Ag electrode deposited on YSZ solid electrolyte, J.K. Hong, I.-H. Oh, S.-A. Hong and W.Y. Lee 89 (1995) 229

XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. I. Hydrogen treatments on a 10 Å thick film, P.C. Wong, Y.S. Li, M.Y. Zhou and K.A.R. Mitchell 89 (1995) 255

XPS investigations of the interactions of hydrogen with thin films of zirconium oxide. II. Effects of heating a 26 Å thick film after treatment with a hydrogen plasma, Y.S. Li, P.C. Wong and K.A.R. Mitchell 89 (1995) 263

Activation treatments and surface study of amorphous $Fe_{90}Zr_{10}$ and $Fe_{87.8}Zr_{10}Co_2Al_{0.2}$ catalysts, X.K. Wang, N.F. Shen, Z.S. Yang and H.C. Gu 89 (1995) 297